## **EEE337/348: Tutorial 2**

1) Consider a Si pn junction with the following parameters.

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Diode area, A = 1 mm<sup>2</sup> p-side doping, N_A = 1 \times 10^{16} \text{ cm}^{-3} n-side doping, N_D = 2 \times 10^{16} \text{ cm}^{-3} Electron diffusion coefficients, D_e = 20 \text{ cm}^2/\text{s} Hole diffusion coefficients, D_h = 12 \text{ cm}^2/\text{s} Electron minority carrier lifetime, \tau_e = 100 \text{ ns} Hole minority carrier lifetime, \tau_h = 10 \text{ ns} Intrinsic carrier concentration, n_i = 1.5 \times 10^{10} \text{ cm}^{-3}
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- i) Calculate the minority carrier diffusion lengths.
- ii) When used as a solar cell, it is important to have a large depletion width. Calculate the depletion width of this diode at 0 V.
- iii) Assuming that when exposed to direct sunlight the electron-hole pair generation rate is constant and is given by  $10^{22}$  cm<sup>-3</sup>s<sup>-1</sup>. Calculate the photocurrent produced.
- iv) Calculate the saturation current in this diode.
- 2) Using values obtained in part (1),
  - i) calculate the open circuit voltage and the short circuit current of the Si diode in part (2).
  - ii) Consider that the diode described in part (1) is a simple planar diode fabricated with a single implantation step and deposition of metal contacts. Discuss additional fabrication procedures that can be adopted to increase  $V_{\text{OC}}$ .
- 3) Consider a solar cell that produces short circuit current  $I_{SC}$  = 25 mA and an open circuit voltage,  $V_{OC}$  = 0.53 V.
  - i) Calculate the maximum power produced by this solar cell if its fill factor is 0.81.
  - ii) Assuming that  $V_m = 0.9 V_{OC}$  and  $I_m = 0.9 I_{SC}$  calculate the number of cells (specify how the cells should be connected) required to produce a total power of 10 W at an output voltage of 10 V.
- 4) Discuss the advantages of using a tandem solar cell over a single junction solar cell.
- 5) Describe the structure of a typical high efficiency 3 junction tandem solar cell. Explain how it works.